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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/928,172	08/09/2001	Chris Parfeniuk	HO57-235	6785	
21567	7590 09/04/2003				
WELLS ST. JOHN P.S. 601 W. FIRST AVENUE, SUITE 1300 SPOKANE, WA 99201			EXAMINER		
			BREWSTER, WILLIAM M		
			ART UNIT	PAPER NUMBER	
			2823		
		•	DATE MAILED: 09/04/2003	DATE MAILED: 09/04/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

		- and				
_	Application No.	Applicant(s)				
Office Action Summers	09/928,172	PARFENIUK ET AL.				
Office Action Summary	Examiner	Art Unit				
	William M. Brewster	2823				
The MAILING DATE of this communication apperiod for Reply	pears on the cover sheet with the o	correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a rep - If NO period for reply is specified above, the maximum statutory portion - Failure to reply within the set or extended period for reply will, by statute - Any reply received by the Office later than three months after the mailin earned patent term adjustment. See 37 CFR 1.704(b). Status	136(a). In no event, however, may a reply be tir ly within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from e, cause the application to become ABANDONE	nely filed rs will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).				
1) Responsive to communication(s) filed on 15	August 2003 .					
	nis action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under Disposition of Claims	Ex parte Quayle, 1935 C.D. 11, 4	153 O.G. 213.				
4)⊠ Claim(s) <u>38-52</u> is/are pending in the application	on.					
4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>38-52</u> is/are rejected.						
7) Claim(s) is/are objected to.	Claim(s) is/are objected to.					
8) Claim(s) are subject to restriction and/o	or election requirement.					
Application Papers						
9) The specification is objected to by the Examiner.						
10) The drawing(s) filed on is/are: a) □ accepted or b) □ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
11)☐ The proposed drawing correction filed on is: a)☐ approved b)☐ disapproved by the Examiner.						
If approved, corrected drawings are required in reply to this Office action.						
12) The oath or declaration is objected to by the Examiner. Priority under 35 U.S.C. §§ 119 and 120						
<u> </u>	a maioritus and an 25 LLC O. C. 440(a) (d) (f)				
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of:						
1. Certified copies of the priority document	s have been received					
2. Certified copies of the priority document		on No				
3. Copies of the certified copies of the prior						
application from the International Bu * See the attached detailed Office action for a list	reau (PCT Rule 17.2(a)).	-				
14) Acknowledgment is made of a claim for domesti	c priority under 35 U.S.C. § 119(e	e) (to a provisional application).				
 a) ☐ The translation of the foreign language provisional application has been received. 15)☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121. 						
Attachment(s)						
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 9	5) Notice of Informal F	(PTO-413) Paper No(s). <u>10</u> . Patent Application (PTO-152)				

Art Unit: 2823

DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 38-43 are rejected under 35 U.S.C. 103(a) as being unpatentable over Hunt et al., U.S. Patent No. 5,836,506, in view of Dunlop et al., U.S. Patent No. 5,590,389.

Hunt (506) teaches, in fig. 5, a physical vapor deposition target 10 construction comprising: a physical vapor deposition target 16 consisting essentially of high purity aluminum material, col. 4, lines 16 - 24, and diffusion bonded, col. 6, line 59 - col. 7, line 31, to an aluminum-containing backing plate, col. 4, lines 24 - 36.

Hunt (506) does not specify the grain diameter of the aluminum target material, but Dunlop does specify this. Dunlop teaches in figs. 6, 7, and 8, a target material made of aluminum 60, col.7, line 3 - col. 8, line 30, and wherein a predominate portion and all of the grains in the target material are: less than 100 μ ms in maximum dimension, less than or equal to about 50 μ ms, approximately 1 μ m, col. 8, lines 3-10. Dunlop gives motivation in col. 1, lines 13 - 25. Even with diffusion bonding, examiner reasonably believes that the AI target maximum dimension of the grain size would be less than or equal to about 50 μ ms in diameter. It would have been obvious to a person

Art Unit: 2823

of ordinary skill in the art at the time the invention was made to recognize that combining Dunlop's process with Hunt (506)'s invention would have been beneficial because it helps produce sputtering with improved manufacturing costs and improves uniformity and deposition rate.

Claims 44-52 are rejected under 35 U.S.C. 103(a) as being unpatentable over Hunt in view of Dunlop as applied to claims 38-43 above, and further in view of Hunt, U.S. Patent No. 6,073,830.

Hunt (506) and Dunlop do not specify the type of aluminum composing their backing plate, but Hunt (830) does. Hunt (830) teaches in fig. 2, a physical vapor deposition target 10, with backing plate 17, comprises a material selected from the group consisting of 2000 Series aluminum, 5000 Series aluminum, 6000 Series aluminum, and 7000 Series aluminum, a 6061 aluminum alloy, col. 9, lines 15 - 24. Hunt (830) gives motivation in col. 3, lines 34-63. It would have been obvious to a person of ordinary skill in the art at the time the invention was made to recognize that combining Hunt (830)'s process with Hunt (506) and Dunlop's invention would have been beneficial because it is more cost effective to provide a two piece construction with a backing plate made from a less expensive material.

Neither Hunt (506), Dunlop, nor Hunt (830) states the bonding strength between the target and the backing plate. However, as the combined invention includes an aluminum target with a maximum grain size between 50 μ ms and 100 μ ms diffusion bonded to a backing material of 6061 aluminum, the invention embodies the physical

Art Unit: 2823

parameters of having bond strength of at least 5000 psi, from about 8000 psi to about 10,000 psi.

Response to Arguments

Applicant's arguments and inventor's affidavit filed 15 August 2003 have been fully considered, however as the USPTO requires in patent prosecution for the examiner to perform a new search. In discovery, the examiner found the Dunlop reference that teaches approximately one-micron grain size for an aluminum sputter target. Examiner reasonably believes that even with diffusion bonding of Dunlop's sputter target, the maximum size of the AI grains would remain below 100 μ ms and even below about 50 μ ms.

As always, the examiner's public service duty is to provide patent protection to novel applications. Examiner will consider new evidence or interviews deemed necessary by the applicants.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to William M. Brewster whose telephone number is 703-305-5906. The examiner can normally be reached on Full Time.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 703-306-2794. The fax phone numbers for the organization where this application or proceeding is assigned are 703-305-3432 for regular communications and 703-305-3432 for After Final communications.

William M. Brewster

Art Unit: 2823

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

Page 5

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29 August 2003